

Visible-Light Photoredox Decarboxylation of Perfluoroarene Iodine(III) Trifluoroacetates for C–H Trifluoromethylation of (Hetero)arenes

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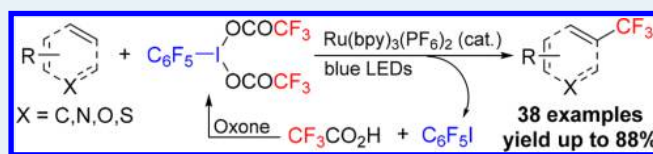
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Supporting Information

ABSTRACT: A scalable and operationally simple decarboxylative trifluoromethylation of (hetero)arenes with easily accessible $C_6F_5I(OCOCF_3)_2$ under photoredox catalysis has been developed. This method is tolerant of various (hetero)arenes and functional groups. Notably, C_6F_5I is recycled from the decarboxylation reaction and further used for the preparation of $C_6F_5I(OCOCF_3)_2$. The combination of photoredox catalysis and hypervalent iodine reagent provides a practical approach for the application of trifluoroacetic acid in trifluoromethylation reactions.

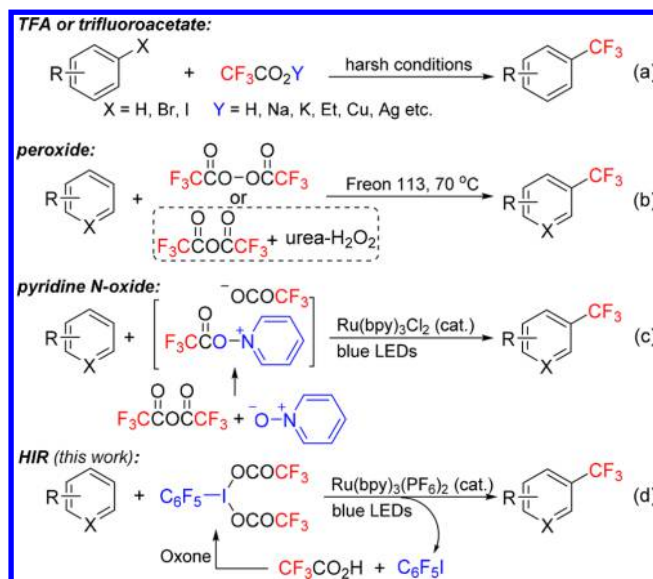
KEYWORDS: trifluoromethylation, photocatalysis, decarboxylation, trifluoroacetic acid, iodine(III) reagent



The trifluoromethylated compounds have found wide applications in materials, pharmaceuticals, and agrochemicals.¹ Over the past decade, tremendous methods have been developed for the incorporation of trifluoromethyl group into organic molecules,² using electrophilic,³ nucleophilic,⁴ and radical⁵ trifluoromethylating reagents. Nonetheless, some of the trifluoromethylating reagents employed in these reactions^{2–5} are cost-prohibitive or gaseous, which limits their application on a large scale. Consequently, the development of new trifluoromethylation reactions with inexpensive and easily handled CF_3 sources is highly desirable.

Because of low cost and the ease of handling,⁶ trifluoroacetic acid (TFA) and its derivatives represent as attractive trifluoromethylating reagents. The decarboxylative trifluoromethylation of TFA and trifluoroacetates has been extensively studied.^{7–10} However, the decarboxylative reactions normally require the electrochemical methods,⁷ stoichiometric transition-metals and high temperature,⁸ or strong oxidants⁹ (see Scheme 1a). Recently, new advancements have been reported to make the decarboxylative trifluoromethylation more generally applicable. For example, Buchwald demonstrated that the application of continuous flow technology could enable the rapid and scalable trifluoromethylation of aryl halides with CF_3CO_2K .^{10a} Zhang and co-workers reported a radical trifluoromethylation of arenes with TFA under the conditions of $Ag_2CO_3/K_2S_2O_8$ at 120 °C.^{10b} Very recently, Su and Li realized a novel photocatalytic C–H trifluoromethylation of (hetero)arenes with TFA using a Rh-modified TiO_2 nanoparticles as a photocatalyst.^{10c} However, these modifications

Scheme 1. Trifluoromethylation Reactions Using TFA and Its Derivatives



could not fundamentally solve the problems, such as high temperature^{10a,b} or strong oxidants.^{10b,c} In 1990, Yoshida and

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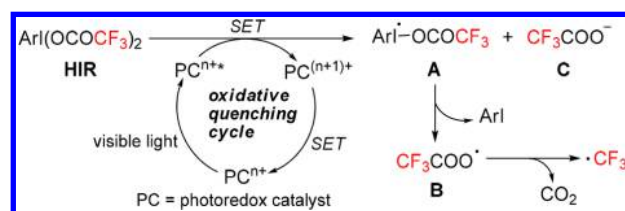


co-workers disclosed an alternative decarboxylative trifluoromethylation of aromatic compounds with bis(trifluoroacetyl) peroxide under mild conditions (Scheme 1b).^{11a} This decarboxylative strategy has recently been adopted by Bräse^{11b} and Sodeoka^{11c} for radical trifluoromethylation of arenes and alkenes using the reagent combination of trifluoroacetic anhydride (TFAA)/urea–hydrogen peroxide (UHP). A significant breakthrough of decarboxylative trifluoromethylation of trifluoroacetic acid (TFA) and its derivatives was made by Stephenson and co-workers.¹² They demonstrated that the pyridine *N*-oxide/TFAA adduct was used to promote a high-yield and scalable trifluoromethylation reaction under photoredox catalysis (Scheme 1c). Despite the above achievements, the development of new trifluoromethylation reactions with TFA derivatives is still highly desirable.

Hypervalent iodine(III) reagents (HIRs) are widely used in organic synthesis, because of their low toxicity, strong electrophilicity, and valuable oxidizing properties.¹³ Recently, hypervalent iodine(III) carboxylates have evolved as powerful reagents to participate in the decarboxylative alkylation, alkenylation, and acylation under transition-metal catalysis¹⁴ or visible-light photoredox catalysis.¹⁵ However, the decarboxylative trifluoromethylation with hypervalent iodine(III) trifluoroacetates (HITFAs) is largely ignored and remains a challenge. In 1991, Togo and Yokoyama reported a decarboxylative alkylation of heteroaromatic bases with carboxylic acids in the presence of HITFAs.^{16a} This work clearly demonstrated that the decarboxylation of HITFAs for the formation of a CF₃ radical was much harder than that of the nonfluorinated HIRs. Very recently, Maruoka described a photolytically induced C–H difluoromethylation of heteroarenes with hypervalent iodine(III) difluoroacetates, but the decarboxylative trifluoromethylation with 3,5-(*t*-Bu)₂C₆H₃I(OCOCF₃)₂ was relatively inefficient.^{16b} In continuation of our research interest in visible-light-induced fluoroalkylation reactions,¹⁷ herein, we disclose a scalable and operationally simple decarboxylative trifluoromethylation of (hetero)arenes with the commercially available C₆F₅I(OCOCF₃)₂ under photoredox catalysis (Scheme 1d). This HIR is easily accessible from C₆F₅I and TFA in the presence of oxone,¹⁸ and C₆F₅I could be recycled from the decarboxylation reaction.

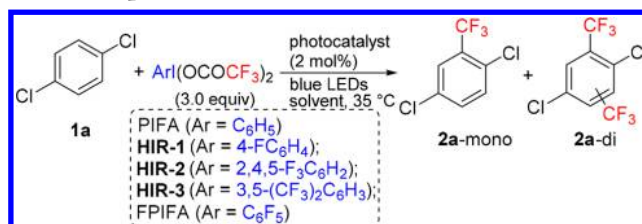
On the basis of visible-light-induced decarboxylation reactions¹⁵ and our experience in decarboxylative hydroaryldifluoromethylation,^{17d} we proposed a photoredox catalytic cycle for decarboxylative trifluoromethylation. As shown in Scheme 2, we assumed that photoredox catalyst (PC) involved single electron transfer (SET) approaches could provide the CF₃ radical (via radical intermediates A and B), which could be used for trifluoromethylation reactions. Importantly, the reactivity and selectivity might be controlled by judicious choice of proper HIRs and PCs.

Scheme 2. Decarboxylative Trifluoromethylation with Hypervalent Iodine Trifluoroacetates



To test our hypothesis, 1,4-dichlorobenzene (**1a**) was chosen as the model substrate to react with C₆H₅I(OCOCF₃)₂ (PIFA) in the presence of Ru(bpz)₃(PF₆)₂ in CH₃CN under blue light-emitting diodes (LEDs). To our disappointment, no trifluoromethylated product was detected (Table 1, entry 1).

Table 1. Optimization of Reaction Conditions^a



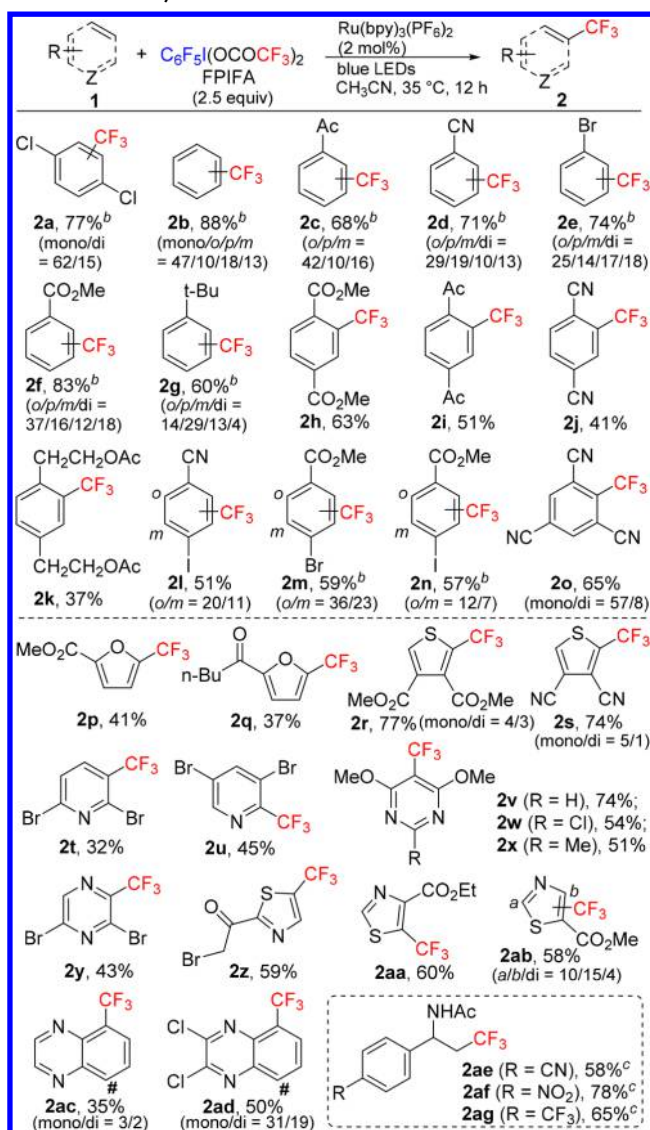
entry	photocatalyst	ArI(OCOCF ₃) ₂	solvent	yield (%) of 2a-mono/2a-di ^b
1	Ru(bpz) ₃ (PF ₆) ₂	PIFA	CH ₃ CN	0/0
2	Ru(bpz) ₃ (PF ₆) ₂	HIR-1	CH ₃ CN	11/0
3	Ru(bpz) ₃ (PF ₆) ₂	HIR-2	CH ₃ CN	23/0
4	Ru(bpz) ₃ (PF ₆) ₂	HIR-3	CH ₃ CN	16/0
5	Ru(bpz) ₃ (PF ₆) ₂	FPIFA	CH ₃ CN	42/trace
6	Ru(bpm) ₃ Cl ₂	FPIFA	CH ₃ CN	51/3
7	Ru(bpy) ₃ (PF ₆) ₂	FPIFA	CH ₃ CN	60/12
8	Ir(ppy) ₃	FPIFA	CH ₃ CN	31/0
9	Ir(Fppy) ₃	FPIFA	CH ₃ CN	29/0
10	Ru(bpy) ₃ (PF ₆) ₂	FPIFA	DMF	0/0
11	Ru(bpy) ₃ (PF ₆) ₂	FPIFA	DCM	0/0
12 ^c	Ru(bpy) ₃ (PF ₆) ₂	FPIFA	CH ₃ CN	60/12
13 ^d	Ru(bpy) ₃ (PF ₆) ₂	FPIFA	CH ₃ CN	62/13
14 ^e	Ru(bpy) ₃ (PF ₆) ₂	FPIFA	CH ₃ CN	62/15
15 ^f	Ru(bpy) ₃ (PF ₆) ₂	FPIFA	CH ₃ CN	0/0
16		FPIFA	CH ₃ CN	8/0

^aReaction conditions: **1a** (0.1 mmol), ArI(OCOCF₃)₂ (0.3 mmol), photocatalyst (0.002 mmol), solvent (1.5 mL), blue LEDs, under N₂, 35 °C, 12 h. ^bYields determined by ¹⁹F NMR using trifluoromethoxybenzene as an internal standard. ^cCF₃COONa (0.1 mmol). ^dKF (0.1 mmol). ^eFPIFA (0.25 mmol). ^fNo light.

Considering the fact that the introduction of fluorine atom(s) or trifluoromethyl group into the aromatic ring of HIRs can distinctly increase their oxidizability and solubility,¹⁹ we then examined a series of fluorinated ArI(OCOCF₃)₂ (Table 1, entries 2–5). To our delight, the desired reaction occurred using fluorinated HIRs, and C₆F₅I(OCOCF₃)₂ (FPIFA) was optimal to give the desired product **2a** in 42% yield (Table 1, entry 5). Switching Ru(bpz)₃(PF₆)₂ to other PCs showed that Ru(bpy)₃(PF₆)₂ gave the highest yield (Table 1, entries 6–9). When this reaction was performed in DMF or DCM, no desired product was formed (Table 1, entries 10 and 11). Furthermore, the addition of a base, such as CF₃COONa or KF, had no or little effect on the yield (Table 1, entries 12 and 13). Finally, decreasing the amount of FPIFA to 2.5 equiv resulted in a comparable yield (Table 1, entry 14). The control experiments showed that the blue LED irradiation was required for this reaction (Table 1, entry 15). **2a** was formed in low yield in the absence of a PC (Table 1, entry 16), which is consistent with the work of Maruoka.^{16b,20}

With the optimized reaction conditions in hand (Table 1, entry 14), the scope of this photoredox-catalyzed decarboxylative trifluoromethylation was investigated (see Scheme 3). Various monosubstituted or disubstituted arenes bearing different functional groups, such as halogen, acetyl, ester, *tert*-

Scheme 3. Substrate Scope of Decarboxylative Trifluoromethylation with FPIFA^a



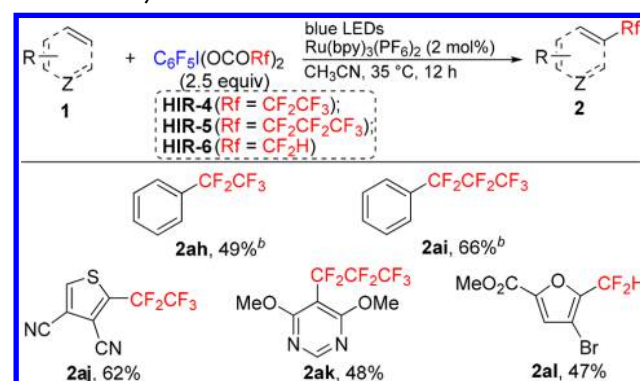
^aReaction conditions: **1** (0.5 mmol), FPIFA (1.25 mmol), Ru(bpy)₃(PF₆)₂ (0.01 mmol), CH₃CN (7.5 mL), blue LEDs, 35 °C, under N₂, 12 h, isolated yields. The isomer ratio was determined by ¹⁹F NMR using trifluoromethoxybenzene as an internal standard. ^bYields determined by ¹⁹F NMR using trifluoromethoxybenzene as an internal standard. ^cFPIFA (0.55 mmol).

butyl, and nitrile, underwent this reaction to afford the corresponding products in moderate to good yields (**2a–2n**). In some cases, the trifluoromethylated products were obtained as mixture of isomers, which is consistent with the general radical trifluoromethylation of arenes.^{5a,10b,c} Moreover, 1,3,5-tricyanobenzene **1o** was smoothly converted to the corresponding trifluoromethylated products (**2o**). The extension of this decarboxylative trifluoromethylation to heteroarenes was delightfully successful. Electro-rich heteroarenes including furans and thiophenes (**1p–1s**) were compatible with the reaction conditions. Meanwhile, electron-deficient heteroarenes (pyridines, pyrimidines, pyrazines, and thiazoles, **1t–1ab**) were also amenable to the reaction. Notably, the trifluoromethylation of these heteroarenes exhibited excellent site-selectivity at the electron-richer position (**2t–2ab**). Unfortunately, pyrroles and

benzopyrroles were not visible for this protocol. In the case of quinoxalines (**1ac** and **1ad**), the trifluoromethylation took place at the C-5 position or both C-5 and C-8 positions (**2ac** and **2ad**), whereas the trifluoromethylation occurred at the C-5 or C-6 position in Baran's CF₃SO₂Na/*t*-BuOOH system.^{5b} The structure of compounds **2aa**, **2ab-b**, and **2ac-di** were confirmed by X-ray analysis (see the Supporting Information). Finally, we extended the substrate scope to styrenes. Treatment of styrenes (**1ae–1ag**) with FPIFA (1.1 equiv) under the standard reaction conditions afforded the aminotrifluoromethylated products (**2ae–2ag**) in moderate to good yields.²¹

To extend the application of this reaction, we then examined the analogous fluoroalkylation reactions with HIRs. Several C₆F₅I(OCORf)₂ (**HIR-4**, **HIR-5**, **HIR-6**) were synthesized²² and subjected to the C–H fluoroalkylation of (hetero)arenes. To our delight, these reactions proceeded smoothly under the standard conditions, resulting in the pentafluoroethylated, heptafluoropropylated, and difluoromethylated products (**2ah–2al**) in moderate yields (see Scheme 4). Unlike the

Scheme 4. Substrate Scope of Decarboxylative Perfluoroalkylation Reaction^a

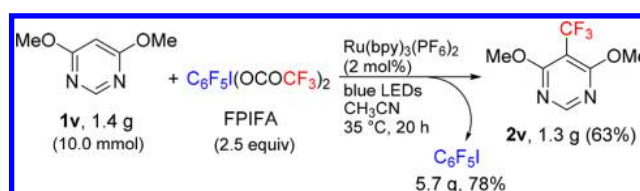


^aReaction conditions: **1** (0.5 mmol), C₆F₅I(OCORf)₂ (1.25 mmol), Ru(bpy)₃(PF₆)₂ (0.01 mmol), CH₃CN (7.5 mL), blue LEDs, 35 °C, under N₂, 12 h, isolated yields. ^bYields determined by ¹⁹F NMR using trifluoromethoxybenzene as an internal standard.

trifluoromethylation reactions, perfluoroalkylation reactions only afforded monosubstituted products, probably because of the higher electronegativity of the perfluoroalkyl group.²³

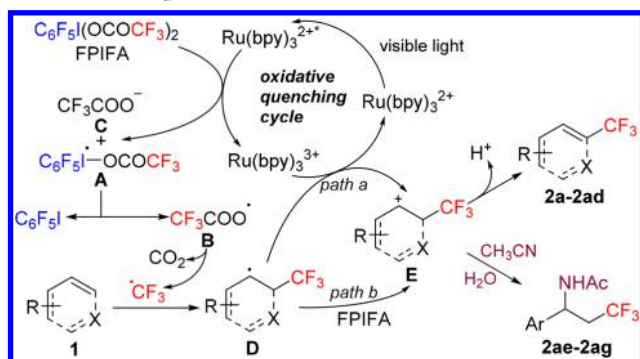
To demonstrate the scalability of the present photocatalytic reaction, the decarboxylative trifluoromethylation of **1v** with FPIFA was carried out on a 10.0 mmol scale (see Scheme 5). The desired product **2v** was isolated in 63% yield (1.3 g), which was slightly inferior to the corresponding reaction presented in Scheme 3. Simultaneously, pentafluoroiodobenzene was recycled in 78% yield (5.7 g) and could be used for the preparation of FPIFA (see the Supporting Information).

Scheme 5. A Gram-Scale Decarboxylative Trifluoromethylation Reaction



On the basis of the results given in Table 1, as well as previous reports,^{15,17d} a plausible reaction mechanism is proposed in Scheme 6. First, irradiation of Ru(bpy)₃²⁺ with

Scheme 6. Proposed Reaction Mechanism



visible light gives the excited-state *Ru(bpy)₃²⁺. Then, SET oxidation of *Ru(bpy)₃²⁺ [$E_{1/2}(\text{Ru}^{\text{II}*}/\text{Ru}^{\text{III}}) = -0.81$ V vs SCE in CH₃CN]²⁴ by FPIFA ($E_{\text{pc}} = -0.08$ V vs SCE in CH₃CN; see the Supporting Information) affords Ru(bpy)₃³⁺ and the iodanyl radical A. The Stern–Volmer fluorescence quenching studies confirmed that FPIFA could quench *Ru(bpy)₃²⁺ effectively (see Figure 1). Subsequently, intermediate A

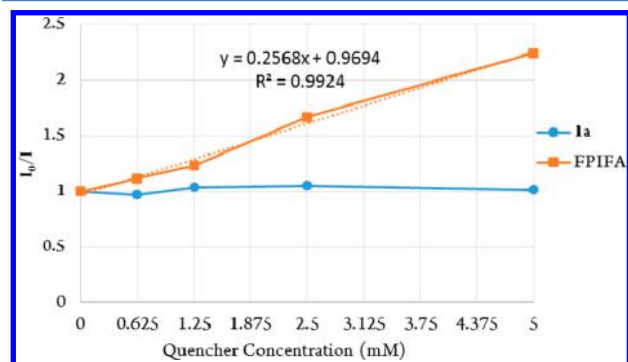
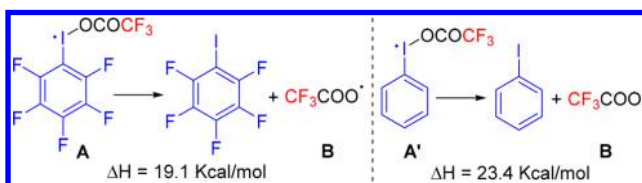


Figure 1. Ru(bpy)₃(PF₆)₂ emission quenching with FPIFA and 1a.

undergoes a homolytic scission of the I–O bond to generate pentafluoroiodobenzene and a trifluoroacetoxy radical B. In this step, the difference of the calculated I–O bond homolytic dissociation enthalpy between intermediates A and A' (see Scheme 7) reveals that the radical intermediate A' from PIFA is harder to process via homolytic scission, which partly interprets why PIFA could not undergo decarboxylative trifluoromethylation reaction (Table 1, entry 1). The resulting radical B extrudes CO₂ to generate the CF₃ radical, which is then added to arenes 1 for the formation of intermediate D. Radical D might be oxidized by Ru(bpy)₃³⁺ (path a in Scheme 6) and/or

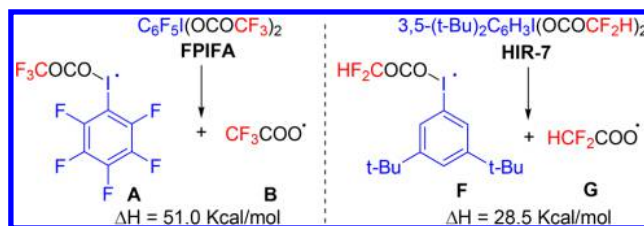
Scheme 7. DFT-Calculated I–O Bond Dissociation Enthalpy for Intermediates A and A' in CH₃CN (M062X/6-311++G**)



FPIFA (path b in Scheme 6) to afford the corresponding cation E. Finally, intermediate E undergoes deprotonation or nucleophilic attack to give the desired products (2).

To compare the current photoredox catalysis decarboxylation trifluoromethylation protocol with Maruoka's photolysis difluoromethylation without photocatalyst,^{16b} the DFT calculations of the I–O bond dissociation enthalpy of PFIPIFA and 3,5-(*t*-Bu)₂C₆H₃I(OCOCF₂H)₂ (HIR-7)^{16b} were conducted. As shown in Scheme 8, the calculated I–O bond homolytic

Scheme 8. DFT-Calculated I–O Bond Dissociation Enthalpy for FPIFA and HIR-7 in CH₃CN (M062X/6-311++G**)



dissociation enthalpy of FPIFA ($\Delta H = 51.0$ kcal/mol) is much higher than that of CF₂H-containing HIR-7 ($\Delta H = 28.5$ kcal/mol). These results explain why a photocatalyst was required for the formation of intermediate A from FPIFA (see Scheme 6).

In conclusion, we have developed a practical visible-light-induced decarboxylative trifluoromethylation of (hetero)arenes using the easily accessible FPIFA as the trifluoromethylating reagent. This method is tolerant of various (hetero)arenes and functional groups. The combination of photoredox catalysis and HIRs provides a practical approach for the application of TFA as a trifluoromethyl source.

■ ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acscatal.7b03990.

Detailed experimental procedures, characterization data, mechanistic study data, copies of ¹H, ¹⁹F, and ¹³C NMR spectra, and X-ray crystal structure of 2aa, 2ab-b, 2ab-di (PDF)

Accession Codes

CCDC 1576960, 1576965, and 1576966 contain the supplementary crystallographic data for this paper. These data can be obtained free of charge via www.ccdc.cam.ac.uk/data_request/cif, or by emailing data_request@ccdc.cam.ac.uk, or by contacting The Cambridge Crystallographic Data Centre, 12 Union Road, Cambridge CB2 1EZ, UK; fax: +44 1223 336033.

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Notes

The authors declare no competing financial interest.

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